

## PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q59993

Isao AMEMIYA

Appln. No.: 09/606,679

Group Art Unit: 2881

Confirmation No.: 8440

Examiner: Erin M. Gill

Filed: June 30, 2000

For: ELECTRON BEAM DRAWING MASK BLANK, ELECTRON BEAM DRAWING

MASK, AND METHOD OF MANUFACTURING THE SAME

## RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents Washington, D.C. 20231

Sir:

In response to the restriction requirement, dated December 18, 2002, Applicant elects Group I, claims 1-36 and 40-86 for examination. This election is made without traverse.

Applicant reserves the right to file a Divisional Application directed to non-elected claims 37-39.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

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WASHINGTON OFFICE

23373
PATENT TRADEMARK OFFICE

Date: January 16, 2003

Alan J. Kasper

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